A Linear-Time Complex-Valued Eigenvalue Solver for Full-Wave Analysis of Large-Scale On-Chip Interconnect Structures

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Abstract—This paper proposes a linear-time complex-valued eigenvalue solver for solving large-scale on-chip interconnect problems. The fast eigenvalue solution is achieved by eigenvalue clustering, fast system reduction with negligible computational cost, and fast linear-time solution of the reduced system. Numerical and experimental results are presented to demonstrate the accuracy and efficiency of the proposed method.

Index Terms—Eigenvalue solver, finite-element methods, frequency domain, full-wave analysis, on-chip interconnects.

I. INTRODUCTION

With continued breakthrough in processing technology, interconnect design has become one of the biggest challenges in the design of today’s and next-generation integrated circuits. Over the past few decades, the modeling of on-chip interconnects has experienced a series of transitions: from lumped capacitance (C), lumped resistance and capacitance (RC), distributed RC, to distributed resistance, inductance, and capacitance (RLC) models. As the clock frequency of microprocessors entered the gigahertz regime, full-wave models have become increasingly important since it is necessary to analyze the chip response to harmonics that are up to five times the clock frequency. In particular, full-wave-based analysis can be used to characterize global electromagnetic coupling through the common substrate and power delivery network.

However, on-chip interconnect structures present many modeling challenges to electromagnetic analysis [1]. These challenges include large problem size, large number of nonuniform dielectric stacks with strong nonuniformity, large number of nonideal conductors, the presence of silicon substrate, highly skewed aspect ratios, etc. In recent years, both partial differential equation (PDE) based solutions and integral equation (IE) based solutions have been developed to address these challenges [2]–[17].

Among these techniques, the frequency-domain eigenvalue-based method in [16] is particularly geared toward full-wave modeling of large-scale on-chip interconnect structures. The original wave propagation problem involves a very large number of unknowns, \( N \), in a 3-D computational domain. Formulated as a generalized eigenvalue problem, the technique in [16] partially addressed the complexity issue by seeking the solutions of only a few 2-D interconnect structures, each involving only \( M(\ll N) \) unknowns in either the \( x-y \)-plane or \( y-z \)-plane (\( y \) is the stack growth direction). These solutions are then post-processed to obtain the solution of the original 3-D problem through an on-chip mode-matching technique. The procedure is rigorous and entails no approximation. Take the test-chip interconnect in [22] for example, \( M = 6678 \), while \( N \) is 10.1 million. In another example [22], \( M = 222K \), while \( N \) is 336 million.

While the complexity is greatly reduced with the construction of \( M \)-parameter models in [16], the problem of finding the solution of the associated modeling problem in \( O(M) \) complexity remains open. The computational bottleneck is the solution of a generalized eigenvalue problem. Efficient algorithms such as ARPACK [18] still require \( O(M^2) \) storage and operations due to dense matrix-vector multiplications. The main contribution of this paper is an algorithm that provides a solution to the generalized eigenvalue problem with \( O(M) \) complexity, thus paving the way for the full-wave simulation of very large scale integration (VLSI) circuits. The \( O(M) \) complexity is achieved by the development of a direct matrix solver of linear complexity in the process of Arnoldi iteration.

In Section II, we give a brief overview of the frequency-domain eigenvalue-based method for full-wave modeling of on-chip interconnects. In Section III, we present the proposed linear-time eigenvalue solver. In Section IV, numerical and experimental results are given to demonstrate the accuracy and efficiency of the proposed solver. Section V relates to our conclusion.

II. REVIEW OF THE FREQUENCY-Domain EIGENVALUE-BASED METHOD

Recognizing that although a 3-D on-chip interconnect structure may consist of a very large number of circuit elements, the number of modes that can be propagated in this structure is orders of magnitude smaller, a frequency-domain eigenvalue-based method was developed in [16] for full-wave modeling of large-scale 3-D on-chip interconnect structures. This method involves a number of important steps, as outlined below.
is the computational domain. and longitudinal electric field denote the relative permeability, relative (1) direction, the total number of structure, and –directions to minimize the number of unknowns in the, and the eigenvectors characterize the transverse elec-
denotes the complex permittivity that accounts for
represents the edge basis function [19] used to
cross sections is the computa-
manhattan-type bus structure made of six metal layers as an ex-
tical bus structure shown in Fig. 1, the number of structure seeds
is only two, i.e., the number of unique x–y cross sections
is orders of magnitude smaller than the number of segments.

C. Eigenvalue-Based Solution

In light of the fact that the electrical properties of intercon-
nects are intrinsic in nature irrespective of the excitation, we construct an eigenvalue-based method for the analysis of an intercon-
nect structure. Inside the interconnect structure, the electric
terface 
subject to certain boundary conditions such as
\[ \hat{n} \times E = 0 \quad \text{on} \quad \Gamma_1 \quad \hat{n} \times (\nabla \times E) = 0 \quad \text{on} \quad \Gamma_2. \] (2)

In (1), \( \mu_r, \varepsilon_r, \) and \( \sigma \) denote the relative permeability, relative permittivity, and conductivity, respectively, \( \Omega \) is the computational domain, which is the cross section of a structure seed including both dielectric and conducting regions, \( \Gamma_1 \) is the boundary where the Dirichlet boundary condition is applied, and \( \Gamma_2 \) is the boundary where the Neumann boundary condition is applied. A finite-element analysis of the boundary value problem defined in (1) and (2) results in the following generalized eigenvalue problem:
\[
\begin{bmatrix}
A_{tt} & 0 \\
0 & B_{tt}
\end{bmatrix}
\begin{bmatrix}
e_t \\
e_z
\end{bmatrix}
= 
\frac{\gamma^2}{k_0^2} 
\begin{bmatrix}
B_{tt} & B_{tz} \\
B_{zt} & B_{zz}
\end{bmatrix}
\begin{bmatrix}
e_t \\
e_z
\end{bmatrix}
\] (3)
in which the eigenvalues correspond to the propagation constants \( \gamma \), and the eigenvectors characterize the transverse electric field \( e_t \) and longitudinal electric field \( e_z \). Matrices \( A \) and \( B \) are complex valued due to the penetration of fields into on-chip conductors. The entries of \( A \) and \( B \) are given by
\[
A_{tt,ij} = \int_{\Omega} \int_{\Omega} \left[ -\frac{1}{k_0^2 \mu_r} \{ \nabla_t \times N_i \} \cdot \{ \nabla_t \times N_j \} \\
+ \varepsilon_r \cdot N_i \cdot N_j \right] d\Omega
\]
\[
B_{tt,ij} = \int_{\Omega} \int_{\Omega} \left[ \frac{1}{\mu_r} N_i \cdot N_j \right] d\Omega
\]
\[
B_{tz,ij} = \int_{\Omega} \int_{\Omega} \left[ \frac{1}{\mu_r} \nabla_t \xi_i \cdot N_j \right] d\Omega
\]
\[
B_{zt,ij} = \int_{\Omega} \int_{\Omega} \left[ \frac{1}{\mu_r} \nabla_z \xi_i \cdot N_j \right] d\Omega
\]
\[
B_{zz,ij} = \int_{\Omega} \int_{\Omega} \left[ \frac{1}{\mu_r} \{ \nabla_z \xi_i \} \cdot \{ \nabla_z \xi_j \} - k_0^2 \varepsilon_r \xi_i \xi_j \right] d\Omega
\] (4)

where \( \xi_r \) denotes the complex permittivity that accounts for conductivity, \( N \) represents the edge basis function [19] used to expand the transverse field, \( \xi \) is the node basis function used to expand the longitudinal one, and \( \Omega \) is the computational domain.
D. On-Chip Mode-Matching Technique

Once (3) is solved, the electric field in each segment can be obtained as

\[ \mathbf{E} = \sum_{m=1}^{n} [\alpha_m \mathbf{e}_m(x, y) e^{-\gamma_m z} + \beta_m \mathbf{e}_m(x, y) e^{\gamma_m z}] \]  

(5)

which is a superposition of all of the forward and backward propagation modes that can be supported by the structure. It should be noted that the \( \mathbf{E} \) field in (5) has all three components \( \mathbf{E}_x, \mathbf{E}_y, \) and \( \mathbf{E}_z \). The unknown coefficients \( \alpha_m \) and \( \beta_m \) in (5) are determined by imposing the following continuity condition at each junction that separates region 1 from region 2:

\[ \sum_{m=1}^{K_1} \xi_{im} \mathbf{e}_{1m,z}(x, y) = \sum_{m=1}^{K_2} \xi_{2m} \mathbf{e}_{2m,z}(x, y) \]
\[ \sum_{m=1}^{K_1} \eta_{im} \mathbf{j}_{1m,z}(x, y) = \sum_{m=1}^{K_2} \eta_{2m} \mathbf{j}_{2m,z}(x, y) \]  

(6)

where \( K_1 \) and \( K_2 \) are the number of modes in region 1 and region 2, respectively, and

\[ \xi_{im} = \alpha_{im} e^{-\gamma_m z} + \beta_{im} e^{\gamma_m z} \]
\[ \eta_{im} = \alpha_{im} e^{\gamma_m z} - \beta_{im} e^{-\gamma_m z}, \quad i = 1 \text{ or } 2 \]  

(7)

and

\[ \mathbf{j}_{1m,z} = j \omega \mathbf{e}_{1m,z} + \sigma \mathbf{e}_{1m,z} \quad \text{and} \quad \mathbf{j}_{2m,z} = j \omega \mathbf{e}_{2m,z} + \sigma \mathbf{e}_{2m,z} \quad i = 1 \text{ or } 2. \]  

(8)

Testing (6) with appropriate functions results in \((K_1 + K_2)\) equations at the junction. Combining this set of equations at each junction with the loading conditions, the unknown coefficients \( \alpha_m \) and \( \beta_m \) can be determined; hence, solving the field anywhere inside the interconnect structure.

III. PROPOSED LINEAR-TIME EIGENVALUE SOLVER

Equation (3) can be compactly written as

\[ \mathbf{A} \mathbf{x} = \lambda \mathbf{B} \mathbf{x}. \]  

(9)

Matrices \( \mathbf{A} \) and \( \mathbf{B} \) are sparse and of size \( O(M) \). The number of eigenvalues that can make a difference in the final solution is generally much less than \( M \), i.e., the number of modes that can propagate in an on-chip structure is generally much less than \( M \). The number of propagation modes of a single stripline, for example, is only one when the electric size of the structure is small although the cross-section size can be very large. The cutoff frequencies of higher order modes are so far away from the cutoff frequency of the dominant mode that the higher order modes are attenuated quickly. When the size is increased or the frequency is increased, more modes can be propagated, but the number of propagation modes is still much less than \( M \). As a result, the computing need here is to find \( K \) selected eigenpairs of the large sparse matrix system shown in (9), where \( K \) is the number of significant modes.

The Arnoldi iteration [18] is particularly suited for this computing task. Consider a standard eigenvalue problem

\[ \mathbf{G} \mathbf{x} = \lambda \mathbf{x}. \]  

(10)

A \( k \)-step Arnoldi process generates an orthonormal basis \( \{v_j\}_{j=1}^{k} \) of the Krylov subspace \( k(v_1, \mathbf{G}) \) spanned by \( v_1, \mathbf{G} v_1, \ldots, \mathbf{G}^{k-1} v_1 \), where \( v_1 \) is an initial unit norm vector. The projected matrix of \( \mathbf{G} \) onto \( k(v_1, \mathbf{G}) \) is represented by a \( k \times k \) upper Hessenberg matrix \( \mathbf{H}_k \). The Ritz pairs of which can be used to approximate the eigenpairs of \( \mathbf{G} \). The algorithm of the \( k \)-step Arnoldi process is as follows:

Algorithm: The \( k \)-step Arnoldi process

1. \( v_1 = v/||v_1|| \)

2. for \( j = 1, 2, \ldots, k \) do
   2.1. \( w = \mathbf{G} v_j; \)
   2.2. for \( i = 1, 2, \ldots, j \) do
       \[ h_{ij} = v_i^* w; \]
       \[ w = w - h_{ij} v_i; \]
   2.3. \( h_{j+1,j} = ||w||, v_{j+1} = w/h_{j+1,j}; \)

The complexity of this algorithm is \( O(Mk^2) \) if \( \mathbf{G} \) is sparse. However, in our problem, \( \mathbf{G} \) is dense because it is equal to \( \mathbf{B}^{-1} \mathbf{A} \) and \( \mathbf{B}^{-1} \) is dense, as can be seen from (3). Therefore, the complexity of a straightforward implementation of the Arnoldi process is \( O(Mk^2 + M^3 + M^2k) \), where the \( O(M^3) \) complexity accounts for the generation of \( \mathbf{G} \), and the \( O(M^2k) \) complexity accounts for the \( k \) dense matrix–vector multiplication operations. As a result, the cost of step 2.1 in (11) can dominate the total computational expense. The key contribution in this paper is the reduction of this computation to \( O(M) \). We will first reduce the system matrix from 2-D to 1-D, then solve the reduced system and recover other unknowns. Three efficient algorithms will be developed to accomplish these two tasks with \( O(M) \) complexity.

A. Eigenvalue Clustering

If the conductors are perfect, i.e., fields do not penetrate into conductors, the real part of the eigenvalues of (3) is bounded between the minimum and maximum relative permittivity. Since the conductors are lossy in a real on-chip environment, the real part is, in fact, bounded in a larger region, but still is bounded as shown in Fig. 2(a). However, the imaginary part can be widely scattered in complex plane due to the conductor loss induced attenuation that is modulated by complicated coupling from surrounding wires. This hinders the fast convergence of an Arnoldi process. To overcome this problem, we transform (9) to

\[ \mathbf{A}' \mathbf{x} = \lambda' \mathbf{B}' \mathbf{x} \]  

(12)

where

\[ \mathbf{A}' = \mathbf{B} - \mathbf{A} \quad \mathbf{B}' = \mathbf{B} + \mathbf{A} \quad \lambda' = \frac{1 - \lambda}{1 + \lambda}. \]  

(13)
we generate a banded matrix formed by submatrices in all segments. The sub-matrix in each x'-segment (the region formed between two vertical lines) can be represented as

\[
\begin{bmatrix}
  e_{y,i} & e_{z,i} & e_{x,i} & e_{y,i+1} & e_{z,i+1} \\
  Q_i & D_i & E_i & & \\
  e_{x,i} & D_i^T & T_i & F_i & \\
  e_{y,i+1} & E_i^T & F_i^T & C_i & \\
\end{bmatrix}
\]  

Each sub-matrix overlaps with its neighbors through matrix \(Q\) and \(C\). Although the overall matrix formed by sub-matrices of the form in (15) is a banded matrix, computation that involves a banded matrix remains expensive when the size is large. To overcome this problem, we first eliminate all the edge unknowns between lines, i.e., horizontal (x'-orientated) edge unknowns. Eliminating these unknowns is equivalent to the following block matrix operation:

\[
\begin{align*}
A_{i,x'} &= Q_i - D_i T_i^T D_i^T \\
B_{i,x'} &= E_i - D_i T_i^T F_i \\
C_{i,x'} &= B_i^T \\
D_{i,x'} &= C_i - F_i^T T_i^T F_i^T \\
\end{align*}
\]  

The right-hand side of (14) needs to also be updated in the reduction process as follows:

\[
\begin{align*}
b_{i1,x'} &= b_{i1} - D_i T_i^T b_{i2} \\
b_{i3,x'} &= b_{i3} - F_i^T T_i^T b_{i2}. \\
\end{align*}
\]  

It is apparent from (16) that in order to eliminate all the horizontal unknowns, one has to fill in matrices \(Q, T, C, D, E, \) and \(F\) for each segment. In addition, one has to evaluate \(DT^{-1}D^T\), \(DT^{-1}F\), and \(F^T T^{-1}F\) for each segment. The required computational cost can be very high when the number of segments is large. It turns out that such computational cost is negligible because the matrices involved exhibit the following properties:

- Matrix \(D\) is the same for all the segments.
- Matrices \(F\) and \(D\) are correlated: \(F = -D^T\)
- Matrix \(Q\) is equal to matrix \(C\) in each segment.
- Matrix \(T\) is linearly proportional to the segment length.
- Matrix \(T\) only needs to be formed and inverted for each unique structure seed.

Although these matrix properties are similar to those in [17], the underlying reasons for them are quite different since the matrices in [17] involved 3-D structures.

As an immediate result of the aforementioned factors, the computational cost of eliminating all the horizontal unknowns is reduced to that of solving \(DT^{-1}D^T\) for each structure seed. The dimension of matrix \(T\) is \(N_y + 1\). When \(T\) is large, the factorization could cost \(O\left(N_y^3\right)\) in both time complexity and space complexity. The operation of \(T^{-1}D^T\) also costs \(O\left(N_y^2\right)\), which is expensive. Here we will reduce the complexity to \(O\left(N_y^2\right)\).

A careful examination of \(T\) reveals that it is a tridiagonal matrix. As can be seen from Fig. 3, each horizontal edge unknown
only has crosstalk with its upper and lower neighbors among all the horizontal unknowns. The inverse of a tridiagonal matrix belongs to the class of hierarchically semiseparable matrices. For a symmetric tridiagonal matrix of order \( n \), there exist two sequences \( \{u_i\}, \{v_i\}, i = 1, 2, \ldots, n \) such that

\[
T^{-1} = \begin{pmatrix}
    u_1v_1 & u_1v_2 & u_1v_3 & \cdots & u_1v_n \\
    u_2v_1 & u_2v_2 & u_2v_3 & \cdots & u_2v_n \\
    u_3v_1 & u_3v_2 & u_3v_3 & \cdots & u_3v_n \\
    \vdots & \vdots & \vdots & \ddots & \vdots \\
    u_nv_1 & u_nv_2 & u_nv_3 & \cdots & u_nv_n
\end{pmatrix}, \quad (18)
\]

Denoting \( T \) as \( tri(a_{1:n}, b_{1:n-1}) \), the sequences \( \{u_i\}, \{v_i\}, i = 1, 2, \ldots, n \) can be generated in \( O(n) \) operations as follows:

\[
d_n = a_n, \quad d_i = a_i - b_{i+1}^2/d_{i+1}, \quad i = n - 1, \ldots, 1 \\
v_1 = \frac{1}{d_1}, \quad v_i = v_{i-1}b_i/d_i, \quad i = 2, \ldots, n \\
\chi_1 = a_1, \quad \chi_i = a_i - b_i^2/\chi_{i-1}, \quad i = 2, \ldots, n \\
u_n = 1/\chi_nv_n, \quad u_{n-i} = b_{n-i+1}u_{n-i+1}/\chi_{n-i}, \quad i = 1, \ldots, n - 1. \quad (19)
\]

Although the inverse of a tridiagonal matrix is dense, with \( n^2 \) entries, it can be compactly represented by \( 2n - 1 \) parameters in \( \{u_i\} \) and \( \{v_i\} \) \( (a_1 = 1) \). In addition, matrix \( D \) is sparse. Hence, the cost of \( DT^{-1}D^T \) scales as \( O(N_x^3/\chi) \).

**Performance Analysis:** The time complexity and space complexity of the aforementioned scheme are both \( O(N_x^3/\chi) \). Since the direction \( y \) is the stack growth direction, \( N_y \) dictates the discretization of the stack. This number is generally much less than \( M \). For example, the interconnect systems of 90-nm technology node involve only 8–9 metal layers. Hence, compared to \( O(M) \), the cost of \( O(N_x^3/\chi) \) is negligible. Furthermore, the cost does not grow with the problem size within each generation as the stack is fixed for each generation.

**C. Solving Reduced System Matrix in \( O(M) \) Complexity**

The reduced system matrix forms a block tridiagonal matrix of order \((2N_y + 1)(N_x + 1)\), which can be denoted by \( S = tri(X_{2:N_y+1}, Y_{1:N_x}). \) Here each \( X_{2:N_y+1}, Y_{1:N_x} \in C^{(2N_y+1)\times(N_x+1)} \). Thus, \( S \in C^{(2N_y+1)(N_x+1)\times(N_x+1)} \) with \( N_x + 1 \) diagonal blocks of size \( 2N_y + 1 \) each. Since the right-hand side of (14) changes at each iteration step of an Arnoldi process, we are specifically interested in its direct solution. Similar to tridiagonal matrices, elegant theoretical results that describe the inverses of block tridiagonal matrices exist. For a symmetric \( mn \times mn \) block tridiagonal matrix \( S \), there exist two sequences of \( m \times m \) matrices \( \{U_i\}, \{V_i\} \) such that for \( j \geq i, (S^{-1})_{ij} = U_iV_j^T \). Thus,

\[
S^{-1} = \begin{pmatrix}
    U_1V_1^T & U_1V_2^T & \cdots & U_1V_n^T \\
    U_2V_1^T & U_2V_2^T & \cdots & U_2V_n^T \\
    \vdots & \vdots & \ddots & \vdots \\
    V_nU_1^T & V_nU_2^T & \cdots & U_nV_n^T
\end{pmatrix}. \quad (20)
\]

While theoretically elegant, the computation of parameters \( \{U_i\} \) and \( \{V_i\} \) is best by numerical problems for even modest-sized problems. The root cause of such an instability is that \( \{U_i\} \) and \( \{V_i\} \) scale exponentially with increasing problem size. Here, we will adopt a variant of the ratio-based approach, which is numerically stable \( [21] \):

\[
U_i = R_iU_{i+1} \\
V_{i+1} = V_iS_i, \quad i = 1, 2, \ldots, N_x \\
R_1 = X_1^{-1}Y_1 \\
R_i = (X_i - Y_i^T R_{i-1})^{-1}Y_i, \quad i = 2, \ldots, N_x \\
S_{N_x} = Y_{N_x}X^{-1}_{N_x+1} \\
S_i = Y_i(X_i+1 - S_{i+1}Y^T_{i+1})^{-1}, \quad i = N_x - 1, \ldots, 1. \quad (21)
\]

As can be seen from (21), the computational cost of obtaining \( \{U_i\} \) and \( \{V_i\} \) is \( O(N_xN_y^3/\chi) \).

Since \( \{U_i\} \) and \( \{V_i\} \) constitute a compact representation of the inverse of a block tridiagonal matrix, the matrix vector multiplication can be performed in an efficient way. For example, \( S^{-1}b \) can be conducted in the following manner:

\[
U_1(V_1^Tb_1 + V_2^Tb_2 + \cdots + V_n^Tb_n) \\
\quad \cdots \quad \cdots \quad \cdots \\
U_2(V_2^Tb_2 + \cdots + V_n^Tb_n) \\
\quad \cdots \quad \cdots \quad \cdots \\
U_n(V_n^Tb_n) \quad (22)
\]

In (22), for clarity, only the upper triangular part is shown. The underlined terms are those that can be incrementally computed from the previous step if one starts from the last row. As a result, for each row, there is only one matrix vector multiplication that needs to be calculated. The same is true for the lower triangular part. Thus, the cost for computing \( S^{-1}b \) is \( O(N_xN_y^3/\chi) \).

**Performance Analysis:** With the aforementioned scheme, the time complexity of step 2.1 in (11) is \( O(N_xN_y^3 + kN_xN_y^2) \). Although the inverse of \( S \) is a dense matrix, with \( \{U_i\} \) and \( \{V_i\} \), which are \( 2N_x + 1 \) matrices of size \( N_y^2 \), \( S^{-1} \) can be stored in \( O(N_xN_y^2) \) memory, while a traditional technique would require \( O(N_xN_y^3) \) memory. In terms of \( M \), the computational complexity is \( O(MN_y^2 + kMN_y) \). As \( N_y \) is much less than \( M \) and the number of dominant eigenvalues \( k \) is small, \( O(MN_y^2 + kMN_y) \approx O(M) \). Similarly, the storage complexity is \( O(MN_y^2) \approx O(M) \).
top of the first, second, and third dielectric layers, 100 inter-
connect wires were placed, and hence, in total 300 intercon-
nect wires were involved in this test structure. Each wire was
0.4975 μm wide, and 0.4975 μm apart from each other hori-
zontally. The frequency of interest was 1 GHz. The proposed
linear-time eigenvalue solver extracted 300 eigenvalues accu-
rately, as can be seen from Fig. 5. As expected, for this example
involving perfect conductors, all the eigenvalues are distributed
between the minimum and maximum relative permittivity. In
this simulation, the number of Arnoldi iterations was chosen as
320. The value of τ was chosen as 3.5. The overall CPU time of
the proposed solver was shown to be 1.5 times faster than that of
MATLAB, or more specifically ARPACK [18], a state-of-the-art
large-scale sparse eigenvalue solver, for eigenvalue computa-
tion. For a fair comparison, we provided MATLAB with the same
and required it to compute only 300 eigenvalues.

With the accuracy and efficiency of the proposed eigenvalue
solver validated, we simulated a test-chip interconnect example,
which was of 300-μm width [22]. It involved a 10-μm-wide
strip in the M2 layer, one ground plane in the M1 layer, and one
ground plane in the M3 layer. This strip was 50 μm to the M2
returns at the left- and right-hand sides. The strip was 2000-μm
long. The reference ground is located at the bottom of M1. The
S-parameters were extracted by the proposed linear-time eigen-
value solver at the near and far ends of the M2 center wire
and compared with measured data. As can be seen clearly from
Fig. 6, there is an excellent agreement.

We also compare the complex eigenvalues extracted by the
proposed solver at different frequency points with measured
propagation constants, as shown in Fig. 7, which again reveals
an excellent agreement. In Fig. 8, we plot the total CPU time
of the proposed linear-time eigenvalue solver at one frequency
point in comparison with that of a conventional Arnoldi-based
eigenvalue solver. The proposed solver clearly outperforms a conventional solver, and its linear complexity can be observed.

The third example is a test-chip interconnect structure, as shown in Fig. 9. The structure was 2000-μm long, consisting of 11 inhomogeneous layers. It involves 12 parallel returns in the M1 and M3 layers, respectively. These returns were 1.05-μm wide and 1 μm apart. They were shorted to the ground at the near and far ends. Two wires were placed in the center of M2. One was of 1.1-μm wide, and the other was of a 2.07-μm width. The spacing between these two wires was 2.0 μm. The distance to M2 returns at the left- and right-hand sides was 10.1 μm. The reference ground is located at the bottom of the silicon substrate. The far ends of the two center wires in M2 were left open. The
S-parameters at the near ends of the two M2 wires were extracted by using the proposed eigenvalue solver and compared with the measured data. Very good agreement can be observed as can be seen from Fig. 10. In Fig. 11, the total CPU time cost by the proposed eigenvalue solver at one frequency point is plotted against that of a conventional Arnoldi-based eigenvalue solver; the advantage of the proposed solver is evident.

In the last example, we simulated a suite of on-chip interconnect structures containing from three wires to 192 wires. The structures were discretized with up to 250K unknowns. Fig. 12(a) shows the decomposition time, i.e., the time for evaluating $(A' - \tau B')^{-1}$ in (14) of the proposed eigenvalue solver as a function of the number of unknowns, and Fig. 12(b) shows the time complexity of evaluating the dense-matrix multiplication in step 2.1 of (11). In both figures, linear complexity can be observed.

V. CONCLUSIONS

In this paper, a linear-time complex-valued eigenvalue solver was developed to solve large-scale on-chip interconnect problems. Numerical and experimental results have demonstrated the accuracy and efficiency of the proposed method.

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